

Title (en)  
DEVICE AND METHOD FOR THERMAL TREATMENT OF A METAL STRIP

Title (de)  
VORRICHTUNG UND VERFAHREN ZUR WAERMEBEHANDLUNG EINES METALLBANDES

Title (fr)  
DISPOSITIF ET PROCÉDÉ DE TRAITEMENT THERMIQUE D'UNE BANDE MÉTALLIQUE

Publication  
**EP 4348143 A1 20240410 (DE)**

Application  
**EP 22711203 A 20220302**

Priority  
• AT 504222021 A 20210527  
• EP 2022055269 W 20220302

Abstract (en)  
[origin: WO2022248089A1] The invention relates to a strip treatment system for the continuous thermal treatment of a metal strip (6), comprising an annealing furnace and a heatable overageing chamber (11) downstream thereof. In the overageing chamber (11), the metal strip (6) is guided over a plurality of vertically spaced deflecting rollers (12, 12', 13, 13') so that the metal strip meanders through the overageing chamber (11). According to the invention, at least one deflecting roller (12', 13') is movable in the vertical direction, thus allowing the strip length or the residence time of the metal strip (6) in the overageing chamber (11) to be adjusted. The invention also relates to a method for the thermal treatment of a metal strip (6).

IPC 8 full level  
**F27B 9/04** (2006.01); **C21D 9/56** (2006.01); **F27B 9/14** (2006.01); **F27B 9/24** (2006.01)

CPC (source: AT EP KR US)  
**C21D 1/02** (2013.01 - AT KR); **C21D 1/34** (2013.01 - EP KR); **C21D 1/76** (2013.01 - EP KR); **C21D 1/767** (2013.01 - KR US);  
**C21D 8/0205** (2013.01 - AT KR); **C21D 9/0062** (2013.01 - EP KR); **C21D 9/46** (2013.01 - EP); **C21D 9/561** (2013.01 - US);  
**C21D 9/563** (2013.01 - EP KR US); **C21D 9/573** (2013.01 - US); **F27B 9/04** (2013.01 - EP KR); **F27B 9/145** (2013.01 - AT EP KR);  
**F27B 9/2407** (2013.01 - EP KR); **F27D 3/12** (2013.01 - AT KR); **C21D 1/767** (2013.01 - EP); **C21D 8/0205** (2013.01 - EP)

Designated contracting state (EPC)  
AL AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HR HU IE IS IT LI LT LU LV MC MK MT NL NO PL PT RO RS SE SI SK SM TR

Designated extension state (EPC)  
BA ME

Designated validation state (EPC)  
KH MA MD TN

DOCDB simple family (publication)  
**WO 2022248089 A1 20221201**; AT 524062 A4 20220215; AT 524062 B1 20220215; BR 112023020447 A2 20231205;  
CA 3217509 A1 20221201; CN 117396716 A 20240112; EP 4348143 A1 20240410; JP 2024522254 A 20240612; KR 20240013719 A 20240130;  
TW 202248427 A 20221216; TW I810861 B 20230801; US 2024229185 A1 20240711

DOCDB simple family (application)  
**EP 2022055269 W 20220302**; AT 504222021 A 20210527; BR 112023020447 A 20220302; CA 3217509 A 20220302;  
CN 202280037599 A 20220302; EP 22711203 A 20220302; JP 2023571185 A 20220302; KR 20237034147 A 20220302;  
TW 111111030 A 20220324; US 202218562550 A 20220302